Institute for Technology Development

ADVANCED MICROELECTRONICS DIVISION

SCALABLE CMOS (SCMOS) DOUBLE METAL I / C STANDARD CELL LIBRARY	**puuf000** PULL_UP	DATE: Dec 21,1988 VERSION: dlmV2.0

********** SPICE DECK **********

*** Generated from puuf000.mag by magicsspicegenerator'
*** technology: scmos
*** timestamp: 598318477
*** version: dlm V2.0
*** Capacitance Threshold = 5000000 units
*** Resistance Scale = 1000 units

M10x22 vdd 20 O vdd PMOS W=4.0U L=36.0U

Cell Device Sizes

Transistor	Width (λ)	Length (λ)
20	4	36

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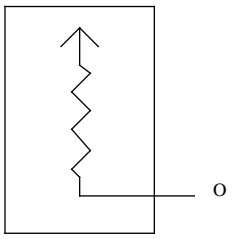
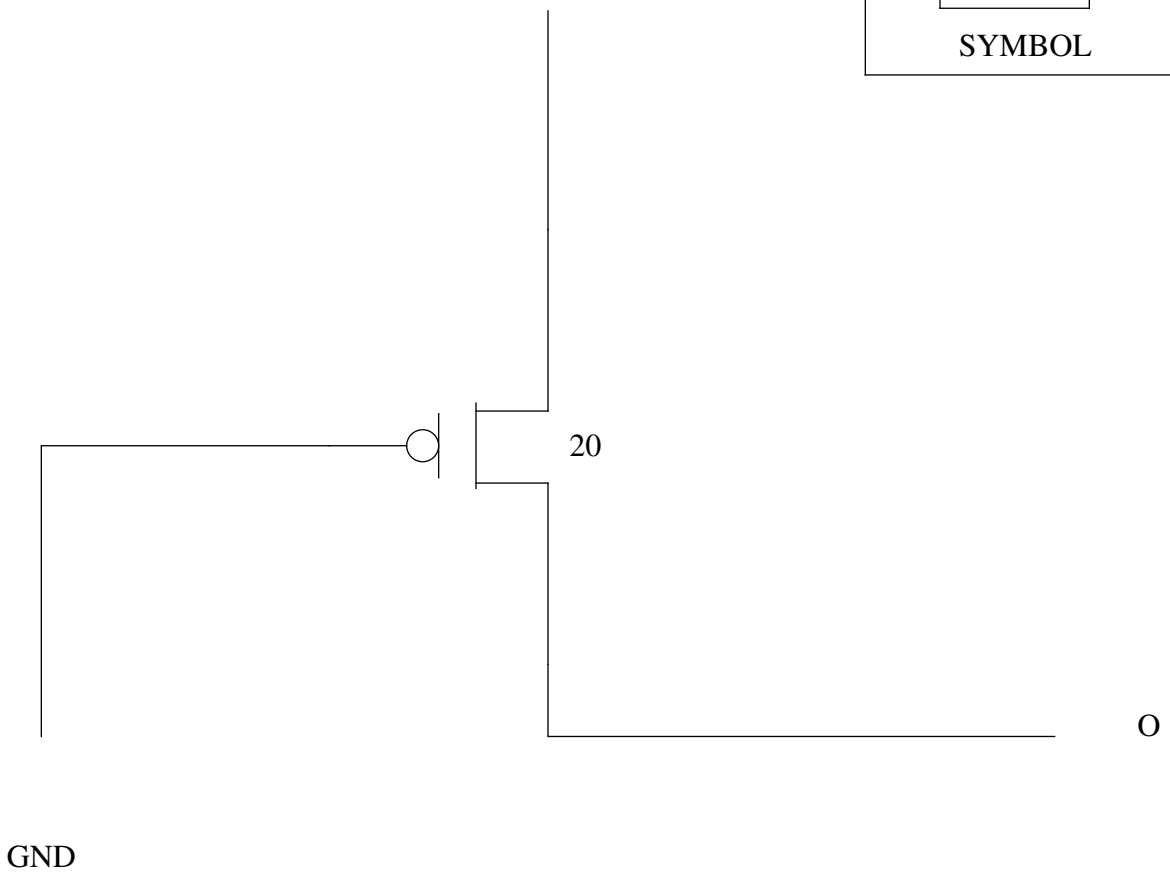


SYMBOL



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TERMINAL LOCATION (In Lambda)

GRID	PIN_NAME	Y_LOC	CLASS
1	FeedThru	----	----
2	O	13	
3	FeedThru	----	----

LOGIC EQUATIONS: O = 1

Truth Table NOT APPLICIABLE